

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:

Peter J. Hopper et al.

Appln. No.: Divisional of 10/219,212

Filed: Herewith

For: METHOD OF FORMING AN ETCHED  
METAL TRACE WITH REDUCED RF  
IMPEDANCE RESULTING FROM THE  
SKIN EFFECT (as amended)

Group Art Unit: Unknown

Examiner: Unknown

PRELIMINARY AMENDMENT

INTRODUCTORY COMMENTS

Mail Stop Patent Application  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This is a Preliminary Amendment. Please amend the above-identified application as indicated on the following pages.